

# Ionizing and non-ionizing radiation damage on Silicon Photomultipliers

Fabio Acerbi<sup>a,b</sup>, A.R. Altamura<sup>a</sup>, B. Di Ruzza<sup>c</sup>, S. Merzi<sup>a</sup>, A. Gola<sup>a,b</sup>

<sup>a</sup> Fondazione Bruno Kessler (FBK), Center for Sensors and Devices, Trento, Italy.
<sup>b</sup> TIFPA Trento Institute for Fundamental Physics and Applications, Trento, Italy
<sup>c</sup> University of Foggia and INFN Bari

acerbi@fbk.eu

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# Single-photon avalanche diode (SPAD) & Silicon Photomultipliers (SiPM)





# Silicon Photomultipliers (SiPMs)

 Silicon Photomultiplier (SiPM): large-area, solid-state, single-photon sensitive detectors, with ph-num. resolution, and large dynamic range.

Applications: medical imaging, high-energy physics, biotech, LiDAR, diffuse optics, others.

□ Active areas: 1x1 mm<sup>2</sup> up to 10x10 mm<sup>2</sup>







# **SiPMs in harsh-radiation environments**



**X- and γ-ray detectors for space experiments** (e.g. SIRI2, GMOD, GRID, AMEGO, ...)





# **Radiation damage in silicon detectors**

- □ Bulk (crystal) damage ← non-ionizing energy loss (NIEL)
  - Displacement damage  $\rightarrow$  crystal defects, interstitials, vacancies, clusters  $\rightarrow$  increased noise.

#### □ Surface damage ← ionizing energy loss (IEL)

Accumulation of charge in the dielectrics; damage of dangling bonds.





#### SiPM: IV and noise source





## FBK SiPMs technologies → irradiated and tested





 $\Box$  Many different SiPM technologies, tailored for different applications  $\rightarrow$  interesting to compare radiation effects.



### **Proton irradiation: irradiation setups**



- □ Proton-therapy center in Trento → IBA cyclotron
- □ "Dual ring setup": 98% uniformity on ~6 cm diameter.  $\rightarrow$  148 MeV source + inhibitor  $\rightarrow$  74 MeV protons
- □ Fluences:  $3 \cdot 10^7 n_{eq}/cm^2$ , ..., **6.4 · 10<sup>11</sup> n\_{eq}/cm^2**



### **Proton irradiation: online IV measurements (in dark)**



March 02, 2023



# Proton irradiation: dark current and DCR variation



□ DCR (primary SRH generation from the bulk) → estimated from the reverse current: we considered ECF and Gain not changing with irradiation (verified up to  $1.10^{11} n_{ed}/cm^2$ )

□ Random fluctuations starting at 10<sup>7</sup> ÷10<sup>8</sup> n<sub>eq</sub>/cm<sup>2</sup>
□ increment of ~4 orders of magnitude at 6.10<sup>11</sup> n<sub>eq</sub>/cm<sup>2</sup> → DCR: 10<sup>9</sup> ÷10<sup>10</sup> cps/mm<sup>2</sup>



## Proton irradiation: DCR activation energy





#### □ Reverse IV measured in the temperature range [-30°C, +30°C]

- 1. Samples not irradiated
- 2. PCB-A (irrad at  $1.4 \cdot 10^{10} n_{eq}/cm^2$  + annealing)
- 3. PCB-B (irrad at  $6.4 \cdot 10^{11} n_{eq}/cm^2$  + annealing)
- **Reduction of temperature dependence (activation energy) with fluence** 
  - → temperature needed to halve the DCR: from  $\sim$ 8°C to  $\sim$ 15°C.
- $\Box$  Dependence of activation energy on excess bias  $\rightarrow$  effect of electric field + possible saturation effects



## Proton irradiation: "damage factor"



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## **Proton irradiation: functional parameters**



#### □ Functional measurements @ -40°C

- Pulse amplitude;
- Prompt crosstalk probability (calculated considering the pile-up effect at high DCR):
- Responsivity (detection efficiency)

 $\rightarrow$  <u>no relevant variations (up to the investigated fluence)</u>

But: after irradiation  $\rightarrow$  high noise  $\rightarrow$  loss of ph. num. resolution



## X-ray irradiation: irradiation setups



#### **X**-ray machine at TIFPA center in Trento

- □ W-anode + Al filter (180um): emission up to  $40kV \rightarrow peaks:7.6 12 keV$
- Doses: 69 Gy, ... ... , 100 kGy (in Silicon) [dose monitor pre-calibrated in a different setup]



# X-ray irradiation: online IV measurements (in dark)



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#### X-ray irradiation: dark current



#### □ Biggest variations on IV curves:

- NUV-HD-lowCT (with abs material in trench)
  - → Electric field modification at the border of AA
- NUV (w/o trench)
  - → Loss of isolations between cells and/or modification of edge electric fields



#### X-ray irradiation: noise and correlated-noise



**\Box** Primary DCR increment  $\rightarrow$  large spread among tech.

• 0.5 ÷ 2.5 orders of magnitude

#### □ Big increment of correlated noise (in some SiPMs)

NUV (w/o trench) and VUV-HD (modified ARC)





# X-ray irradiation: detection efficiency





350

400

450 500

Measurements of the photon detection efficiency (PDE) 

- No variation in the NUV-HD SiPMs (n-type epi/sub.)
- Important variation in the RGB-HD (p-type epi/sub.)

 $\rightarrow$  More important at high wavelengths

650 700 750 800 850

550

900 950



# X-ray irradiation: structure modifications



#### $\Box$ Effect of X-ray irradiation $\rightarrow$ positive charge trapped in dielectric layers (e.g. SiO<sub>2</sub>)

- P-type epi → additional electric field peak in depth
  - $\rightarrow$  enhanced border region  $\rightarrow$  lower effective FF
- **N-type epi**  $\rightarrow$  enhanced electric field close to the trenches (defective region)
  - $\rightarrow$  possible higher DCR and Afterpulsing



#### **Room temperature annealing**



#### Studied room-temperature annealing (Measured 2 times per day for several weeks)

#### Proton irradiation: exponential decrease (2 slopes)

• Max factor 0.5 recovery  $\rightarrow$  need high temperatures

#### □ X-ray irradiation: exponential decrease (1 slopes)

Much higher DCR recovery



## Conclusions

#### Tested the effect of lonizing and non-ionizing radiation

Fluencies/doses compatible with experiments working in space environments

#### Protons at 74 MeV, up to 6.10<sup>11</sup> n<sub>eq</sub>/cm<sup>2</sup>

- more than 4 orders of magnitude increment on primary DCR
- Reduction of activation energy  $\rightarrow$  cooling less effective
- No relevant modification of all other SiPM functional parameters

#### X-ray at 40 keV, up to 100 kGy

- Moderate increment of primary noise (DCR),
- Important modification of the internal electric field profiles and functional parameters of SiPMs:
  - N-type epi/sub structures (p-on-n junction)  $\rightarrow$  increment of DCR and afterpulsing probability
  - P-type epi/sub structures (n-on-p junction) → reduction of effective AA, thus of PDE





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